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ABSTRACT

Disclosed herein are a light-emitting device of tip emission type which maintains a stable emission efficiency without leakage current and a process for production of the light-emitting device. The light-emitting device (10) consists of a substrate (1), a lower electrode (4), an organic layer (6) which include at least an emission layer (6c), and a transparent upper electrode (7) provided on the organic layer (6) which are sequentially formed on top of the other. The lower electrode (4) has a double-layer structure composed of a metallic layer (2c) and a buffering thin film (3c) formed thereon. The buffering thin film (3c) is formed from an oxide of the metallic material constituting the metallic layer (2c), the oxide having a higher conductivity than the organic layer (6), or formed from an oxide of chromium. The thus formed buffering thin film (3c) reduces the surface roughness of the metallic layer (2c) in the lower electrode (4) of double-layer structure. The reduced surface roughness provides a uniform space between the lower electrode (4) and the transparent upper electrode (7).